



# *“ Component Risk Mitigation Strategies “*

*April, 10 2011*

*Dynamic Research and Testing Laboratories,  
LLC (DRTL)*

*Authors :*

*Mark Northrup*

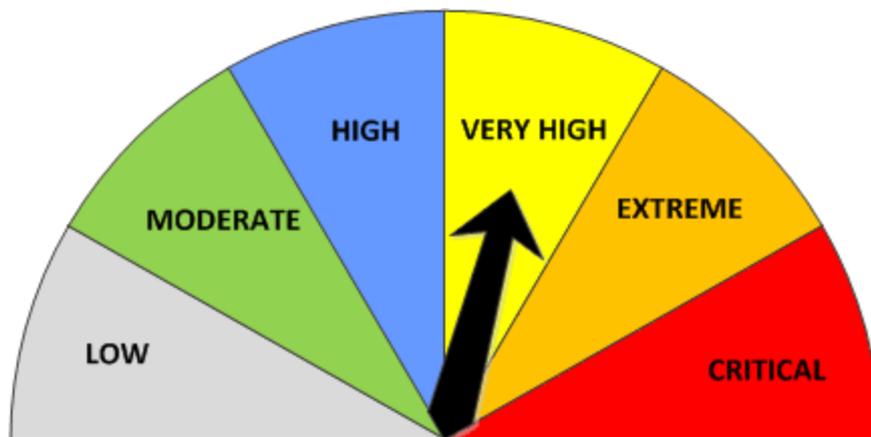
*Clifton Aldridge*



## *Risk Mitigation ?*

What is the definition of Risk Mitigation ?

*A systematic reduction in the extent of exposure to a risk and/or the likelihood of its occurrence.*

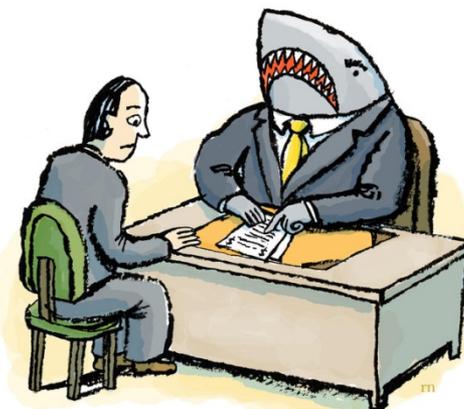
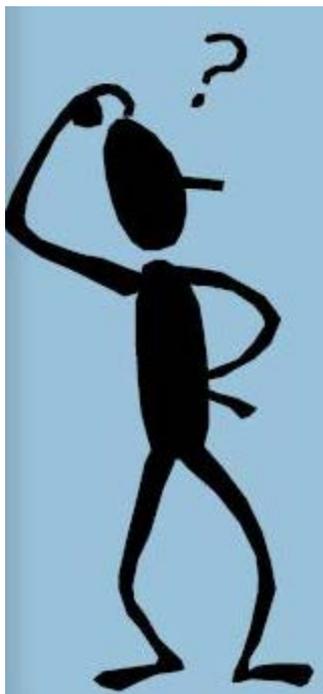


# COMPONENTS

## *Risk Mitigation Testing Strategies Examples*

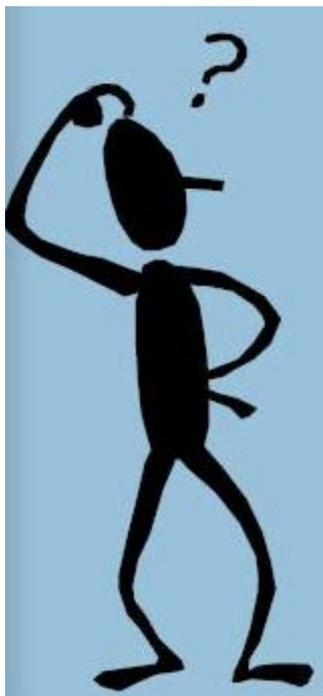
### Testing Plan Strategies

- BASIC
- IDEA 1010
- AS5553C
- MIL-STD-1580
- Custom



# COMPONENTS

## *Risk Mitigation Testing Strategies Examples*



### Testing Laboratory Certifications

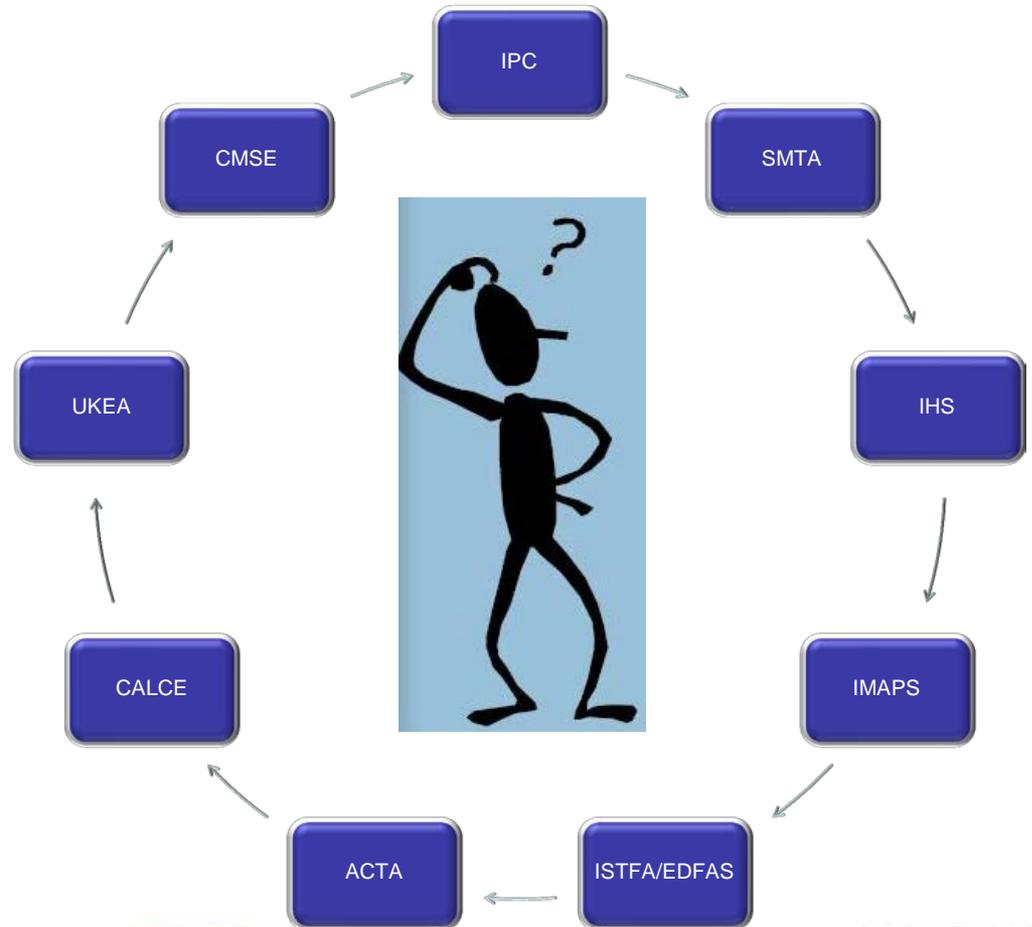
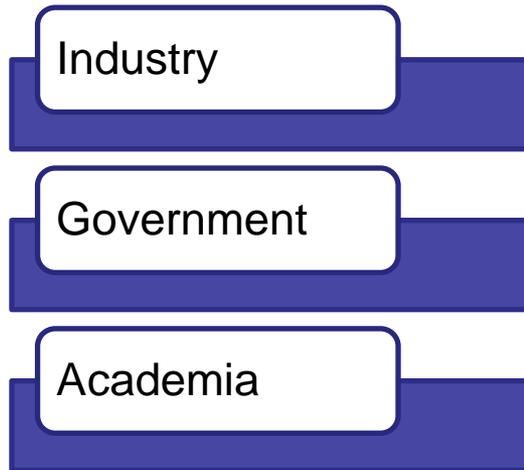
- ISO/IEC 9000
- ISO/IEC 17025
- AS9100
- AS6171
- NADCAP
- DLA/QML



# COMPONENTS

*Risk Mitigation Testing Affiliations*

## Affiliations



# COMPONENTS

## *IDEA – 1010 Risk Mitigation Testing Strategies*

### IDEA – STD – 1010 ACCEPTABILITY OF ELECTRONIC COMPONENTS DISTRIBUTED IN THE OPEN MARKET

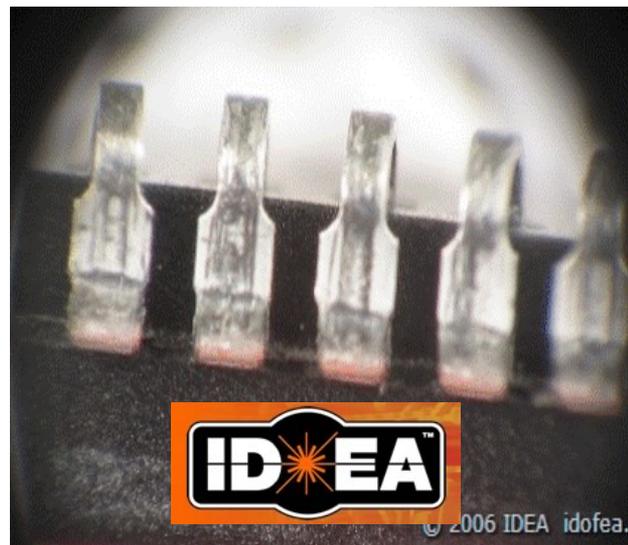
**1.1 Scope :** The Standard sets forth practices and requirements for visual examination and acceptability criteria of electronic components purchased and sold in the open market . Practices are generally accepted industry methods and are provided in the Standard for guidance only; they are not mandatory. Requirements are mandatory conditions essential for indicating acceptable products in accordance with the Standard.



# COMPONENTS

## IDEA – 1010 Risk Mitigation Testing Strategies

Appearance 10-7	13.2 Acceptable 13-3
10.12 Date Codes 10-8	13.3 Damaged Leads and Terminations 13-8
10.13 Lot Codes 10-8	13.4 Contamination and Oxidation 13-16
10.14 Co-Planarity 10-9	13.5 Evidence of Poor Handling or Storage 13-23
10.14.1 Component Testing 10-9	13.6 Evidence of Prior Use 13-34
10.14.2 Pre-Authorizations for Testing 10-9	13.7 Evidence of Rework/Refurbishment 13-50
10.14.3 Test Services and Records 10-10	13.8 Evidence of Use or Damage 13-60
12.3 Possible Indications of Counterfeit and Substandard Parts 12-3	13.9 Remarked and Suspect Counterfeit/Fraud 13-63
12.3.1 Outside Appearance 12-3	14 Relevant Standards Generating Bodies and Trade Associations 14-1
12.7.1 Read the Shipping Box and Packing Materials 12-8	14.1 Standards Distributors 14-3
12.7.2 Read the Product Packaging 12-8	14.2 Relevant Quality Institutions 14-3
12.7.3 Read the Part 12-9	14.3 Relevant International Trade Institutions 14-3
12.7.4 Further Determining Defects 12-10	15 Appendix A 15-1
13 Clauses – Acceptability vs. Unacceptable Characteristics for Electronic Components by Photos and Text 13-1	16 INDEX 16-1
13.1 Acceptance Criteria 13-1	17 Improving this Standard 17-2



# COMPONENTS

## *AS5553 Risk Mitigation Testing Strategies*

### SAE AS5553 COUNTERFEIT ELECTRONICS PARTS; AVOIDANCE DETECTION, MITIGATION, AND DISPOSITION

**1.1 Scope.** This SAE Aerospace Standard standardizes practices to:

- a. Maximize availability of authentic parts
- b. Procure parts from reliable sources
- c. Assure authenticity and conformance of procured parts
- d. Control parts identified as counterfeit
- e. And report counterfeit parts to other potential users and Government investigative authorities.



**G-19 Counterfeit Electronic Parts Committee**

# COMPONENTS

## AS5553 Risk Mitigation Testing Strategies

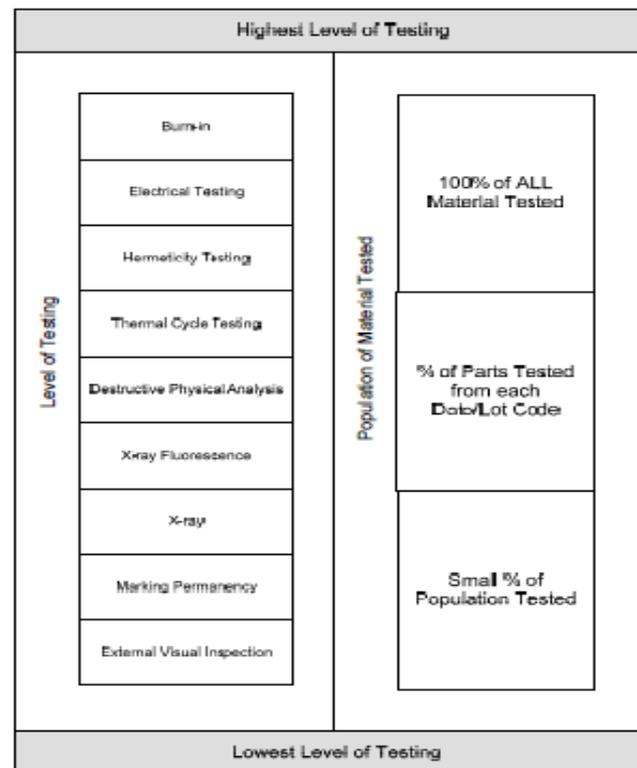
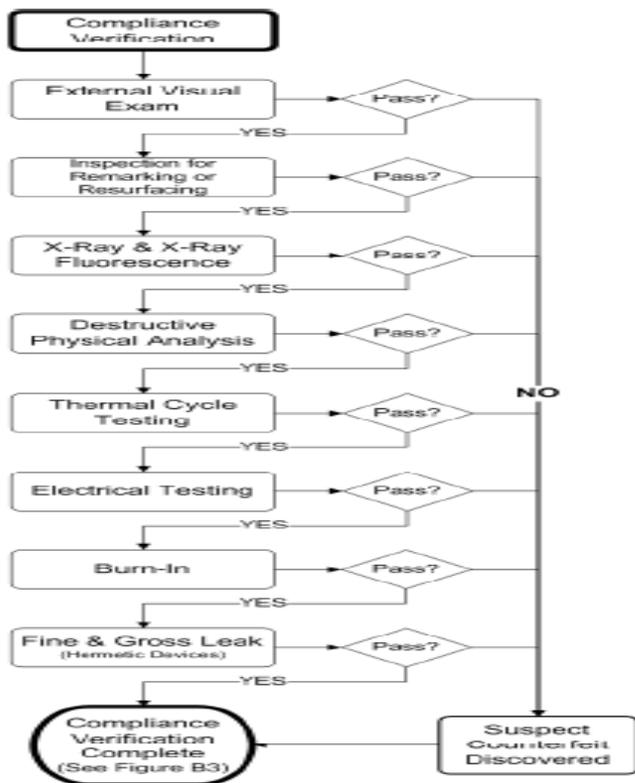


FIGURE E2 - TEST EVALUATION RISK STACK CHART

# COMPONENTS

## *Mil-Std-1580 Risk Mitigation Testing Strategies*

### MIL-STD-1580 DEPARTMENT OF DEFENSE TEST METHOD STANDARD DESTRUCTIVE PHYSICAL ANALYSIS FOR ELECTRONIC, ELECTROMAGNETIC, AND ELECTROMECHANICAL PARTS

**1.1 Scope.** This standard describes the general requirements for performance of **destructive physical analysis (DPA)** on samples of parts. In addition to the requirements for the analysis procedures, the general criteria for interpreting results, such as for the acceptance or rejection of associated production lots, is included for typical electronic, electromagnetic, and electromechanical parts.

**1.2 Application of the standard.** This standard; is intended to be referenced, in detailed part specifications; or in other documents where DPA requirements are imposed, to assure that the practices, procedures, and criteria contained herein are uniformly applied. The requirements are intended to provide the general framework and basis for detailed DPA procedures for specific part types.



# COMPONENTS

## *Mil-Std-1580 Risk Mitigation Testing Strategies(883)*

**1.1 Scope.** This standard describes the general requirements for performance of destructive physical analysis (DPA) on samples of parts. In addition to the requirements for

**1.1 Purpose.** This standard establishes uniform methods, controls, and procedures for testing microelectronic devices suitable for use within Military and Aerospace electronic systems including basic environmental tests to determine resistance to deleterious effects of natural elements and conditions surrounding military and space operations; mechanical and electrical tests; workmanship and training procedures; and such other controls and constraints as have been deemed necessary to ensure a uniform level of quality and reliability suitable to the intended applications of those devices. **For the purpose of this standard, the term "devices" includes such items as monolithic, multichip, film and hybrid microcircuits, microcircuit arrays, and the elements from which the circuits and arrays are formed. This standard is intended to apply only to microelectronic devices.** The test methods, controls, and procedures described herein have been prepared to serve several purposes:

- a. To specify suitable conditions obtainable in the laboratory and at the device level which give test results equivalent to the actual service conditions existing in the field, and to obtain reproducibility of the results of tests. The tests described herein are not to be interpreted as an exact and conclusive representation of actual service operation in any one geographic or outer space location, since it is known that the only true test for operation in a specific application and location is an actual service test under the same conditions.
- b. To describe in one standard all of the test methods of a similar character which now appear in the various joint-services and NASA microelectronic device specifications, so that these methods may be kept uniform and thus result in conservation of equipment, manhours, and testing facilities. In achieving this objective, it is necessary to make each of the general tests adaptable to a broad range of devices.
- c. To provide for a level of uniformity of physical, electrical and environmental testing; manufacturing controls and workmanship; and materials to ensure consistent quality and reliability among all devices screened in accordance with this standard.



# COMPONENTS

## *Mil-Std-1580 Risk Mitigation Testing Strategies(202)*

### MIL-STD-202 DEPARTMENT OF DEFENSE TEST METHOD STANDARD ELECTRONIC AND ELECTRICAL COMPONENT PARTS



- 1.1 Purpose.** This standard establishes uniform methods for testing electronic and electrical component parts, including basic environmental tests to determine resistance to deleterious effects of natural elements and conditions surrounding military operations, and physical and electrical tests. **For the purpose of this standard, the term "component parts" includes such items as capacitors, resistors, switches, relays, transformers, inductors, and others. This standard is intended to apply only to small component parts, weighing up to 300 pounds or having a root mean square test voltage up to 50,000 volts unless otherwise specifically invoked.** The test methods described herein have been prepared to serve several purposes:
- To specify suitable conditions obtainable in the laboratory that give test results equivalent to the actual service conditions existing in the field, and to obtain reproducibility of the results of tests. The tests described herein are not to be interpreted as an exact and conclusive representation of actual service operation in any one geographic location, since the only true test for operation in a specific location is an actual service test at that point.
  - To describe in one standard (1) all of the test methods of a similar character which appeared in the various joint or single-service electronic and electrical component parts specifications, (2) those test methods which are feasible for use in several specifications, and (3), the recognized extreme environments, particularly temperatures, barometric pressures, etc., at which component parts will be tested under some of the presently standardized testing procedures. By so consolidating, these methods may be kept uniform and thus result in conservation of equipment, man-hours, and testing facilities. In achieving these objectives, it is necessary to make each of the general tests adaptable to a broad range of electronic and electrical component parts.
  - The test methods described herein for environmental, physical, and electrical tests shall also apply, when applicable, to parts not covered by an approved military specification, military sheet form standard, specification sheet, or drawing.

# COMPONENTS

## *Mil-Std-1580 Risk Mitigation Testing Strategies(750)*

### MIL-STD-750 DEPARTMENT OF DEFENSE TEST METHOD STANDARD TEST METHODS FOR SEMICONDUCTOR DEVICES

**1.1 Purpose.** This standard establishes uniform methods for testing semiconductor devices, including basic environmental tests to determine resistance to deleterious effects of natural elements and conditions surrounding military operations, and physical and electrical tests. **For the purpose of this standard, the term "devices" includes such items as transistors, diodes, voltage regulators, rectifiers, tunnel diodes, and other related parts. This standard is intended to apply only to semiconductor devices.** The test methods described herein have been prepared to serve several purposes:

- a. To specify suitable conditions obtainable in the laboratory that give test results equivalent to the actual service conditions existing in the field, and to obtain reproducibility of the results of tests. The tests described herein are not to be interpreted as an exact and conclusive representation of actual service operation in any one geographic location, since it is known that the only true test for operation in a specific location is an actual service test at that point.
- b. To describe in one standard all of the test methods of a similar character which now appear in the various joint-services semiconductor device specifications, so that these methods may be kept uniform and thus result in conservation of equipment, man-hours, and testing facilities. In achieving this objective, it is necessary to make each of the general tests adaptable to a broad range of devices.
- c. The test methods described herein for environmental, physical, and electrical testing of devices shall also apply, when applicable, to parts not covered by an approved military sheet-form standard, specification sheet, or drawing.



# COMPONENTS

## *Mil-Std-1580 Risk Mitigation Testing Strategies*

### MIL-STD-883 DEPARTMENT OF DEFENSE TEST METHOD STANDARD MICROCIRCUITS

#### **METHOD NO. ENVIRONMENTAL TESTS**

- |  |   |
|--|---|
| 1001 Barometric pressure, reduced (altitude operation) | 1016.2 Life/reliability characterization tests                            |
| 1002 Immersion   | 1017.2 Neutron irradiation  |
| <i>1003 Insulation resistance</i>                      | <i>1018.6 Internal gas analysis</i>                                       |
| <i>1004.7 Moisture resistance</i>                      | 1019.8 Ionizing radiation (total dose) test procedure                     |
| <i>1005.9 Steady state life</i>                        | 1020.1 Dose rate induced latchup test procedure                           |
| 1006 Intermittent life                                 | 1021.3 Dose rate upset testing of digital microcircuits                   |
| 1007 Agree life  | 1022 Mosfet threshold voltage   |
| 1008.2 Stabilization bake                              | 1023.3 Dose rate response of linear microcircuits                         |
| 1009.8 Salt atmosphere (corrosion)                     | 1030.2 Preseal burn-in  |
| <i>1010.8 Temperature cycling</i>                      | 1031 Thin film corrosion test   |
| <i>1011.9 Thermal shock</i>                            | 1032.1 Package induced soft error test procedure (due to alpha particles) |
| <i>1012.1 Thermal characteristics</i>                  | 1033 Endurance life test  |
| 1013 Dew point   | <i>1034.1 Die penetrant test (for plastic devices)</i>                    |
| 1014.13 Seal   |   |
| <i>1015.10 Burn-in test</i>                            |   |



# COMPONENTS

## *Mil-Std-1580 Risk Mitigation Testing Strategies*

### **MECHANICAL TESTS**

2001.3 Constant acceleration

2002.5 Mechanical shock

*2003.9 Solderability*

*2004.6 Lead integrity*

2005.2 Vibration fatigue

2006.1 Vibration noise

2007.3 Vibration, variable frequency

2008.1 Visual and mechanical

*2009.10 External visual*

*2010.12 Internal visual (monolithic)*

*2011.8 Bond strength (destructive bond pull test)*

*2012.8 Radiography*

*2013.1 Internal visual inspection for DPA*

*2014 Internal visual and mechanical*

*2015.13 Resistance to solvents*

*2016 Physical dimensions*

*2017.9 Internal visual (hybrid)*

*2018.5 Scanning electron microscope (SEM) inspection  
of metallization*

*2019.8 Die shear strength*

*2020.9 Particulate impact noise detection test(PIND)*

2021.3 Glassivation layer integrity

*2022.2 Wetting balance solderability*

*2023.6 Nondestructive bond pull*

2024.2 Lid torque for glass-frit-sealed packages

*2025.4 Adhesion of lead finish*

2026 Random vibration

2027.2 Substrate attach strength

2028.4 Pin grid package destructive lead pull test

2029 Ceramic chip carrier bond strength

2030.1 Ultrasonic inspection of die attach

2031.1 Flip chip pull-off test

2032.2 Visual inspection of passive elements

2035 Ultrasonic inspection of TAB bonds

*2036 Resistance to soldering heat*



# COMPONENTS

## *Mil-Std-1580 Risk Mitigation Testing Strategies*

### **ELECTRICAL TESTS (DIGITAL)**

- 3001.1 Drive source, dynamic
- 3002.1 Load conditions
- 3003.1 Delay measurements
- 3004.1 Transition time measurements
- 3005.1 Power supply current
- 3006.1 High level output voltage
- 3007.1 Low level output voltage
- 3008.1 Breakdown voltage, input or output
- 3009.1 Input current, low level
- 3010.1 Input current, high level
- 3011.1 Output short circuit current
- 3012.1 Terminal capacitance
- 3013.1 Noise margin measurements for digital microelectronic devices
- 3014 Functional testing
- 3015.8 Electrostatic discharge sensitivity classification
- 3016 Activation time verification
- 3017 Microelectronics package digital signal transmission
- 3018 Crosstalk measurements for digital microelectronic device packages
- 3019.1 Ground and power supply impedance measurements for digital microelectronics device packages
- 3020 High impedance (off-state) low-level output leakage current
- 3021 High impedance (off-state) high-level output leakage current

### **ELECTRICAL TESTS (LINEAR)**

- 4001.1 Input offset voltage and current and bias current
- 4002.1 Phase margin and slew rate measurements
- 4003.1 Common mode input voltage range
- Common mode rejection ratio/Supply voltage rejection ratio
- 4004.2 Open loop performance
- 4005.1 Output performance
- 4006.1 Power gain and noise figure
- 4007 Automatic gain control range



# COMPONENTS

## *Mil-Std-1580 Risk Mitigation Testing Strategies*

### **METHOD NO. TEST PROCEDURES**

- 5001 Parameter mean value control
- 5002.1 Parameter distribution control
- 5003 Failure analysis procedures for microcircuits
- 5004.11 Screening procedures
- 5005.15 Qualification and quality conformance procedures
- 5006 Limit testing
- 5007.7 Wafer lot acceptance
- 5008.9 Test procedures for hybrid and multichip microcircuits
- 5009.1 Destructive physical analysis**
- 5010.4 Test procedures for custom monolithic microcircuits
- 5011.5 Evaluation and acceptance procedures for polymeric adhesives.
- 5012.1 Fault coverage measurement for digital microcircuits.
- 5013 Wafer fabrication control and wafer acceptance procedures for processed GaAs wafers

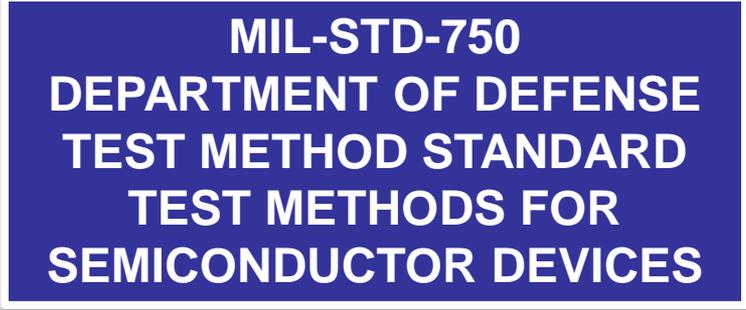


# COMPONENTS

## *Mil-Std-1580 Risk Mitigation Testing Strategies*

### Environmental tests (1000 series).

- 1001.2 Barometric pressure (reduced).
- 1011.1 Immersion.
- 1015.1 Steady-state primary photocurrent irradiation procedure (electron beam).
- 1016 Insulation resistance.
- 1017.1 Neutron irradiation.
- 1018.3 Internal gas analysis.
- 1019.5 Steady-state total dose irradiation procedure.
- 1020.2 Electrostatic discharge sensitivity (ESDS) classification.
- 1021.3 Moisture resistance.
- 1022.5 Resistance to solvents.
- 1026.5 Steady-state operation life.
- 1027.3 Steady-state operation life (sample plan).
- 1031.5 High-temperature life (non-operating).
- 1032.2 High-temperature (non-operating) life (sample plan).
- 1033 Reverse voltage leakage stability
- 1036.3 Intermittent operation life.
- 1037.2 Intermittent operation life (sample plan).
- 1038.4 Burn-in (for diodes, rectifiers, and zeners).
- 1039.4 Burn-in (for transistors).
- 1040 Burn-in (for thyristors (controlled rectifiers)).
- 1041.3 Salt atmosphere (corrosion).
- 1042.3 Burn-in and life test for power MOSFET's or insulated gate bipolar transistors (IGBT).



**MIL-STD-750**  
**DEPARTMENT OF DEFENSE**  
**TEST METHOD STANDARD**  
**TEST METHODS FOR**  
**SEMICONDUCTOR DEVICES**

- 1049 Blocking life (sample plan).
- 1051.6 Temperature cycling (air to air).
- 1054.1 Potted environment stress test.
- 1055.1 Monitored mission temperature cycle.
- 1056.7 Thermal shock (liquid to liquid).
- 1057.1 Resistance to glass cracking.
- 1061.1 Temperature measurement, case and stud.
- 1066.1 Dew point.
- 1071.8 Hermetic seal.
- 1080 Single event burnout and single event gate rupture test.



# COMPONENTS

## *Mil-Std-1580 Risk Mitigation Testing Strategies*

### Environmental tests (100 class)

101E	Salt atmosphere (corrosion) (formerly called salt spray)
102A	Superseded by Method 107 (see note on Method 102)
103B	Humidity (steady state)
104A	Immersion
105C	Barometric pressure (reduced)
106G	Moisture resistance
107G	Thermal shock
108A	Life (at elevated ambient temperature)
109C	Explosion
110A	Sand and dust
111A	Flammability (external flame)
112E	Seal

**MIL-STD-202  
DEPARTMENT OF DEFENSE  
TEST METHOD STANDARD  
ELECTRONIC AND  
ELECTRICAL COMPONENT  
PARTS**



### Physical characteristics tests (200 class)

208H	Solderability
209	Radiographic inspection
210F	Resistance to soldering heat
211A	Terminal strength
212A	Acceleration
213B	Shock (specified pulse)
214A	Random vibration
215K	Resistance to solvents
217A	Particle impact noise detection (PIND)

### Electrical characteristics tests (300 class)

301	Dielectric withstanding voltage
302	Insulation resistance
303A	DC resistance
304	Resistance temperature characteristic
305A	Capacitance
306	Quality factor (Q)
307	Contact resistance

# IPC BOX BUILD GUIDELINE BLOCKS

Testing  
Services  
(TM-650)

Box Build(IPC-630)  
& System

PCB(IPC600)

PCBA(IPC610)

Components(?)

Cables & Harness  
(IPC-620)

Connectors(IPC620)

# COMPONENTS

*Risk Mitigation Testing Strategies*

## Three Step Component Risk Mitigation Procedure



# COMPONENTS

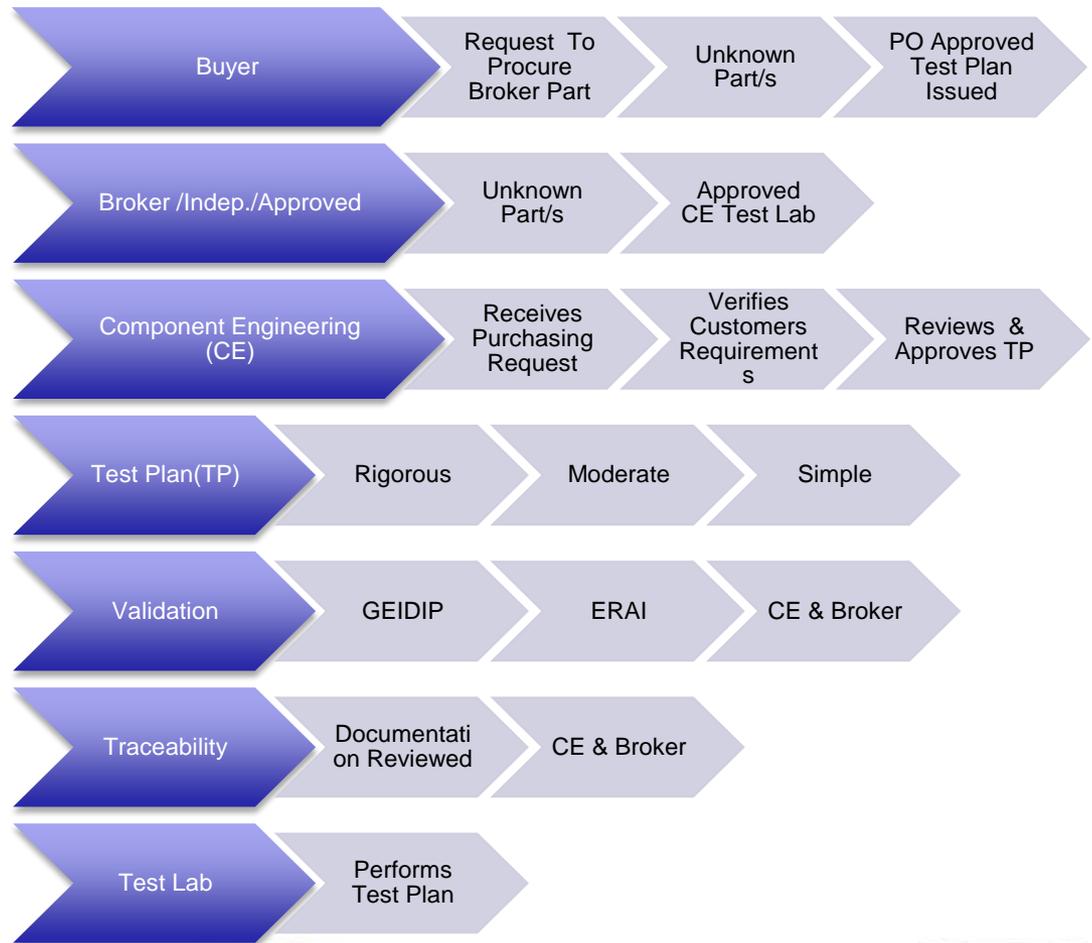
*Risk Mitigation Testing Strategies*

## Step 1 – Customer Identifies The Application



# Typical Procurement Structure

## Step 2 – Component Test Plan Defined



# COMPONENTS

*Risk Mitigation Testing Strategies*  
( IDEA-1010, AS5553, Mil-Std-1580, Custom)

## Step 2 – Component Test Plan Defined

### HIGH

- DPA (MIL-STD-1580)
- External Visual(2009.10)
- Internal Visual(2013.1)
- X-ray(2012.8)
- XRF(1580B 5.1)
- CSAM(2030.1)
- Solderability(2013.9)
- Environmental Stress Test
- Thermal Shock(1011.9)
- SEM(2018.5)
- EDX/EDS(1580B 9)
- FTIR/TGA
- Electrical Test
- Burn-in(1015.10)
- Fine & Gross Leak(1014.13)
- RGA(1018.6)
- PIND(2020.9)

### MEDIUM

- AS5553C
- DPA
- External Visual
- Internal Visual
- Marking Permanency
- Inspection  
  Remarking/Resurface
- X-ray
- XRF(JESD 213)
- Thermal Cycle
- Electrical Test
- Burn-in
- Fine & Gross Leak

### LOW

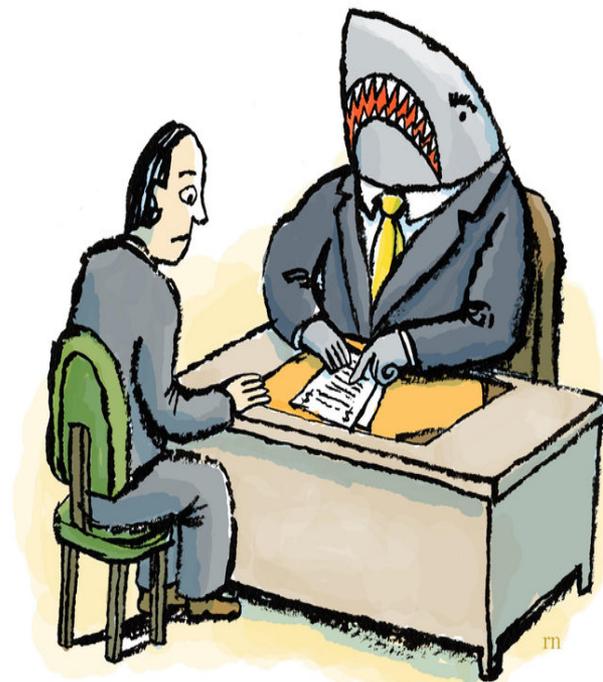
- IDEA 1010
- Photograph Parts
- Co-planarity
- Damaged Leads and Terminations
- Contamination and Oxidation
- Evidence of Poor Handling, Storage or Prior Use
- Rework or Refurbishment
- Remarked and Suspect Counterfeit/Fraud



# The Only True Component Risk Mitigation Solution

*Risk Mitigation Testing Strategies*  
(IDEA -1010, AS5553, Mil-Std-1580, Custom)

## *Design Out Obsolescence ?*





# Customer Submission Request Form

*Risk Mitigation Testing Strategies  
( IDEA-1010, AS5553, Mil-Std-1580, Custom)*

## **Optical Microscopy**

MIL-STD-883, Method 2010  
Method 2013, Method 2017  
MIL-STD-750, Internal Visual

## **X-Ray Fluorescence (XRF)**

JESD213  
MIL-STD-1580, Reqmt. 9

## **Real-Time X-Ray Inspection**

MIL-STD-883, Method 2012  
MIL-STD-750, Method 2076  
MIL-STD-202, Method 209

## **Seal Testing**

MIL-STD-883, Method 1014  
MIL-STD-750, Method 1071  
MIL-STD-202, Method 112

## **Fluorescent Microscopy**

MIL-STD-883, Method 1014

## **FTIR/TGA**

ASTM E1252, E2105

## **Chemical Decapsulation**

Industry Accepted Standards

## **Cross-Sectioning**

DPA MIL-STD-1580

## **Temperature Cycling**

MIL-STD-883, Method 1010  
MIL-STD-750, Method 1051  
MIL-STD-202, Method 107

## **Particle Impact Noise Detection (PIND)**

MIL-STD-883, Method 2020  
MIL-STD-750, Method 2052  
MIL-STD-202, Method 217

## **Wire-Pull**

MIL-STD-883, Method 2011  
MIL-STD-750, Method 2037

## **Die Shear**

MIL-STD-883, Method 2019  
MIL-STD-750, Method 2017

## **Scanning Electron Microscopy (SEM)**

MIL-STD-750, Method 2077  
MIL-STD-883, Method 2018

## **Energy Dispersive X-Ray Spectroscopy (EDS)**

ASTM E1508

## **C-Mode Scanning Acoustic Microscopy (CSAM)**

IPC/JEDEC  
J-STD-035

## **Electrical Testing/Screening**

MIL-STD-883  
MIL-STD-750  
MIL-STD-202

## **HAST**

JESD22-A1 10D  
JESD22-A1 18A

# Customer Submission Request Form

## Risk Mitigation Testing Strategies

(IDEA-1010, AS5553, Mil-Std-1580, Custom)



### DRTL REPORT

REVISION TABLE			
REV	DATE	ENG APPROVAL	NOTES
-	03-04-11	CLIFTON ALDRIDGE	Initial Release

INTERNAL PROGRAM-CUSTOMER:		ADDITIONAL INFORMATION:	
SO#:			
DATE RECEIVED:	03-02-11		
PART NUMBER:	935101-1 (MS75089-11)	CUSTOMER I	
SERIAL NUMBER:	NONE	NONE	
MANUFACTURER:	Delevan		

### Dynamic Research and Testing Laboratories, LLC



Dynamic Research and Testing Laboratories LLC  
1450 Mission Ave NE  
Albuquerque, NM 87101

(505)263-0398  
caldrige@DRTLOnline.com

### Invoice

DATE	INVOICE #
03/06/2011	1009
TERMS	DUE DATE
Net 30	04/05/2011

#### Incoming Complaint:

Incoming complaint was customer had reported intermittent series resista to the nigh higher assemble.

#### Detail:

The following parts were supplied for testing.  
Lot # 207111, D/C 1049 = 233, D/C 1032 = 22, D/C 1035 = 45  
Lot # 205790, D/C 1035 = 300  
Lot # 202407, D/C 1035 = 3  
The 205790 and 202407 lots (both of date code 1035) were electrical test

<b>BILL TO</b>
XYZ4
XYZ4
XYZ4, NY

AMOUNT DUE	ENCLOSED
\$1,550.00	

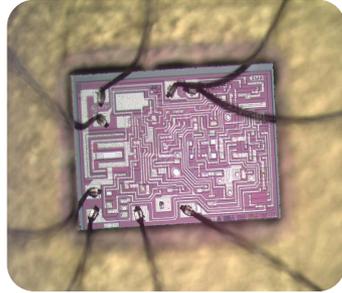
Please detach top portion and return with your payment.

Activity	Quantity	Rate	Amount
• Standard DPA per MIL-STD-1580 Requirement 10 for Capacitors	1	550.00	550.00
• Standard Level 2 Destructive Physical Analysis	1	1,000.00	1,000.00

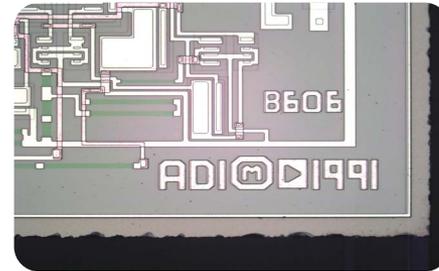


# SERVICES – Optical Microscopy

*Risk Mitigation Testing Strategies  
( IDEA-1010, AS5553, Mil-Std-1580, Custom)*



Internal Visual  
Mil-Std-750/883



# SERVICES – Real Time X-ray Inspection

*Risk Mitigation Testing Strategies*  
( IDEA-1010, AS5553, Mil-Std-1580, Custom)

Radiographic Inspection per Mil-Std- 202, 750, 883?



# SERVICES – XRF (X-ray Fluorescence)

*Risk Mitigation Testing Strategies  
( IDEA-1010, AS5553, Mil-Std-1580, Custom)*



ELMUT FISCHER GmbH + Co. KG  
 Industriestrasse 21  
 71069 Sindelfingen

**Fischer**

Fischerscope® XRAY XDAL  
 Product: 1 / ENIG Dir.: PCB Rigid Block: 9  
 Application: 24 / ENIG

## XRF

Calibration: Standard free  
 n= 1 Au 1 = 27.6 µm NiP 2= 297.0 µm Cu 3 = 2.35 µm

Mean	27.61 µm	297.0 µm	2.347 µm
Standard deviation	----- µm	----- µm	----- µm
C.O.V. (%)	0.00	0.00	0.00
Range	0.000 µm	0.000 µm	0.000 µm
Number of readings	1	1	1
Min. reading	27.6 µm	297.0 µm	2.35 µm
Max. reading	27.6 µm	297.0 µm	2.35 µm
Measuring time	30 sec		
Operator: CCA	SMT Osc	na	
Date: 7/23/2010	Time: 9:24:13 AM		

**MIL-STD-1580**

**JESD213**



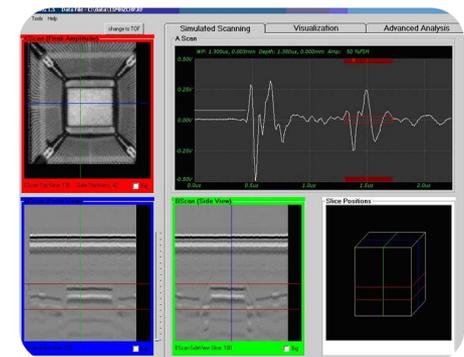
# SERVICES - CSAM

*Risk Mitigation Testing Strategies  
( IDEA-1010, AS5553, Mil-Std-1580, Custom)*



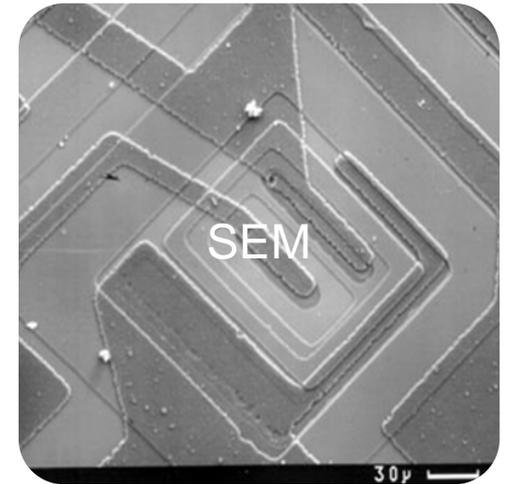
CSAM

J-Std-035



# SERVICES – SEM/EDX

*Risk Mitigation Testing Strategies  
( IDEA-1010, AS5553, Mil-Std-1580, Custom)*



Mil-Std -750



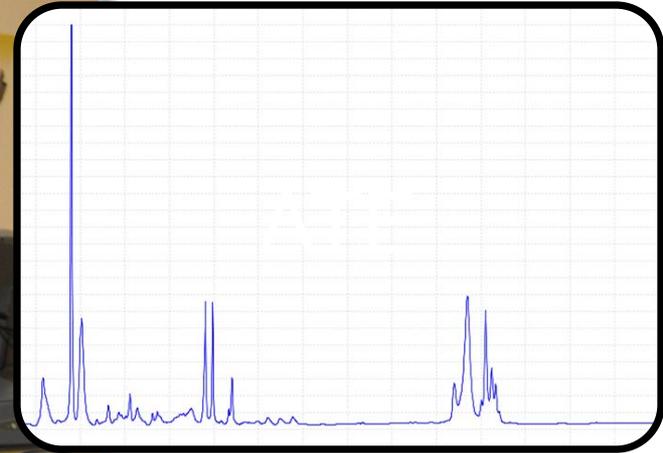
Mil -Std-883

# SERVICES – uFTIR/TGA

*Risk Mitigation Testing Strategies  
( IDEA-1010, AS5553, Mil-Std-1580, Custom)*



**FTIR**



**TGA**

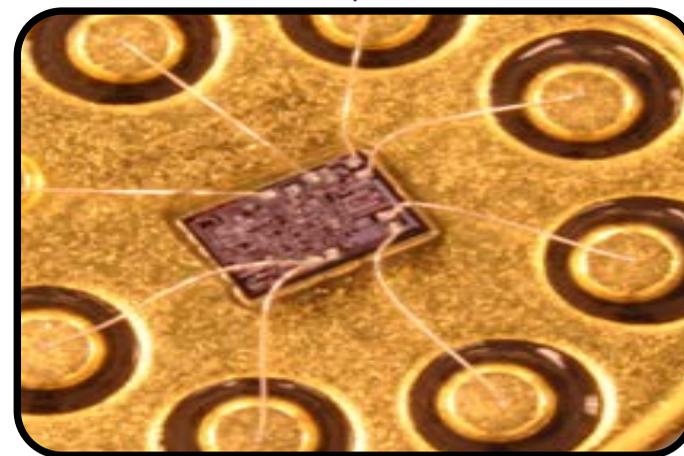


# SERVICES – Wire-pull/Die Shear

*Risk Mitigation Testing Strategies*  
( *IDEA-1010, AS5553, Mil-Std-1580, Custom* )



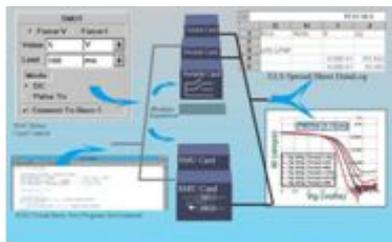
Wire-Pull  
Mil-Std-883 / 2011



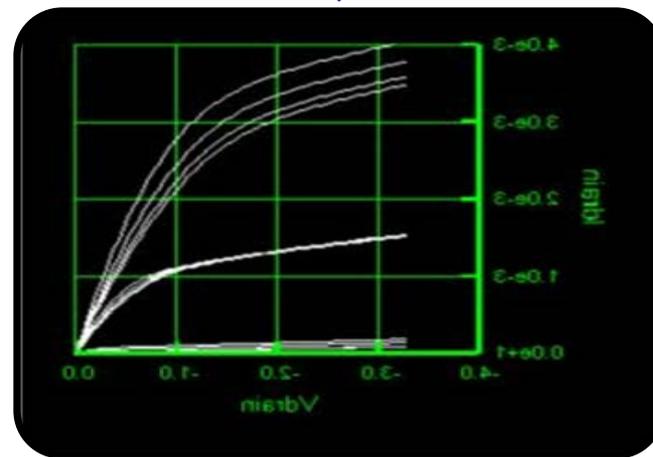
Die Shear  
Mil –Std – 883/2019

# SERVICES – Electrical

*Risk Mitigation Testing Strategies*  
( IDEA-1010, AS5553, Mil-Std-1580, Custom)



HFE



Idss

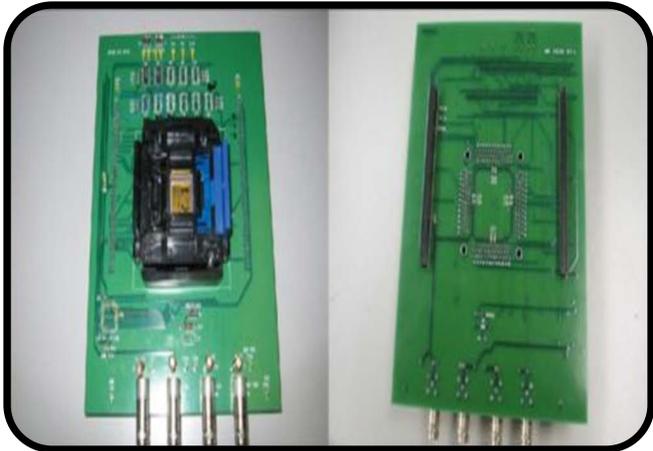


# SERVICES – Environmental

*Risk Mitigation Testing Strategies*  
( *IDEA-1010, AS5553, Mil-Std-1580, Custom* )



HAST



THERMAL  
CYCLE

# Questions- *Thank you*

*Risk Mitigation Testing Strategies*  
( *IDEA-1010, AS5553, Mil-Std-1580, Custom* )

